



Docket No.: 0039-7632-0X

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

RE: Inventor: Hiroyuki YANO, et al.

Patent No.: 6,740,590

Issued: May 25, 2004

Group Art Unit: 1765

Examiner: Duy-Vu Deo

For: AQUEOUS DISPERSION, AQUEOUS DISPERSION
FOR CHEMICAL MECHANICAL POLISHING USED
FOR MANUFACTURE OF SEMICONDUCTOR
DEVICES, METHOD FOR MANUFACTURE OF
SEMICONDUCTOR DEVICES, AND METHOD FOR
FORMATION OF EMBEDDED WIRING

SIR:

Attached hereto for filing are the following papers:

REQUEST FOR CERTIFICATE OF CORRECTION
CERTIFICATE OF CORRECTION FORM PTO 1050

Our check in the amount of -0- is attached covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R 1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. A Duplicate copy of this sheet is enclosed.

Respectfully Submitted,

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MAIER & NEUSTADT, P.C.
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DOCKET NO.: 0039-7632-0X/ehw



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Hiroyuki YANO, et al.

PATENT NO.: 6,740,590

GROUP: 1765

ISSUED: May 25, 2004

EXAMINER: Duy-Vu Deo

FOR: AQUEOUS DISPERSION, AQUEOUS DISPERSION FOR CHEMICAL MECHANICAL POLISHING USED FOR MANUFACTURE OF SEMICONDUCTOR DEVICES, METHOD FOR MANUFACTURE OF SEMICONDUCTOR DEVICES, AND METHOD FOR FORMATION OF EMBEDDED WIRING

REQUEST FOR CERTIFICATE OF CORRECTION

DIRECTOR OF THE UNITED STATES PATENT AND TRADEMARK OFFICE
ALEXANDRIA, VA 22313-1450

SIR:

The following is a request for a certificate of correction in Serial Number 09/531,163, now Patent Number 6,740,590.

In accordance with the provisions of Rule 322 of the Rules of Practice, which implement 35 USC 254, the Patent Office is respectfully requested to issue a certificate of correction in the above-identified patent.

In light of the fact that the errors were the fault of the Patent Office, no fees are required. The requested corrections are listed on FORM P.T.O. 1050.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.
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UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : **6,740,590**
DATED: **May 25, 2004**
INVENTOR(S): **Yano et al.**

It is certified that an error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

On the title page, Item (54), and in Column 1 the title information should read:

-- (54) **AQUEOUS DISPERSION, AQUEOUS DISPERSION FOR CHEMICAL
MECHANICAL POLISHING USED FOR MANUFACTURE OF
SEMICONDUCTOR DEVICES, METHOD FOR MANUFACTURE OF
SEMICONDUCTOR DEVICES, AND METHOD FOR FORMATION OF
EMBEDDED WIRING --**

Mailing address of sender:

Patent No. **6,740,590**

Customer Number
22850

No. of add'l copies
@ .30 per page

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